



1 Secondary Organic Aerosols from OH Oxidation of Cyclic Volatile Methyl Siloxanes as an Important

- 2 Si Source in the Atmosphere
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- 12 Short summary: We presented yields and compositions of Si-containing SOA generated from the reaction
- 13 of cVMS (D3-D6) with OH radicals. NO_x played negative roles on cVMS SOA formation, while ammonium
- 14 sulfate seeds enhanced D3-D5 SOA yields at short photochemical ages under high-NO_x conditions. The
- 15 aerosol mass spectra confirmed that the components of cVMS SOA significantly relied on OH exposure. A
- 16 global cVMS-derived SOA source strength was estimated to understand SOA formation potentials of cVMS.
- 17

18 Abstract

Cyclic volatile methyl siloxanes (cVMS) are active ingredients in widely used consumer products, which can volatilize into the atmosphere, thus attracting much attention due to their potential environmental risks. While in the atmosphere the cVMS undergo oxidation yielding both gaseous and particulate products. The aerosol yields and compositions from the OH oxidation of four cVMS (D3-D6) were determined under low





23	and high-NO _x conditions in an oxidation flow reactor. The aerosol yields progressively increased from D3
24	to D6, consistent with the volatilities and molecule weights of these cVMS. NO _x can restrict the formation
25	of SOA, leading to lower SOA yields under high-NO _x conditions than under low-NO _x conditions, with a
26	yield decrease between 0.05-0.30 depending on the cVMS. Ammonium sulfate seeds exhibited minor
27	impacts on SOA yields under low-NOx conditions, but significantly increased the SOA yields in the oxidation
28	of D3-D5 at short photochemical ages under high-NO $_x$ conditions. The mass spectra of the SOA showed a
29	dependence of its chemical compositions on OH exposure. At high exposures, equivalent to photochemical
30	ages of >6 days in the atmosphere, D4-D6 SOA mainly consisted of C_xH_y and $C_xH_yO_zSi_n$ under low-NO _x
31	conditions, whereas they primarily contained N_mO_z , C_xH_y , $C_xH_yO_1$, $C_xH_yO_{>1}$ and $C_xH_yO_zSi_n$ under high-NO _x
32	conditions. Using the yield data from the present study and reported cVMS annual production, a global
33	cVMS-derived SOA source strength is estimated to be 0.16 Tg yr ⁻¹ , distributed over major urban centers.

34

35 1 Introduction

Secondary organic aerosols (SOA), which contribute 50-85% to the mass of atmospheric organic aerosols (OA) (Glasius and Goldstein, 2016), are mainly formed via the partitioning of low volatility products from oxidation of volatile organic compounds (VOCs), semi- and intermediate volatile organic compounds(S/IVOCs) (Riipinen et al., 2012). SOA has attracted significant attention due to their important impacts on climate, ecosystems and human health (Berndt et al., 2016). Global budgets of SOA remain an unresolved issue despite extensive research, largely due to uncertainties associated with aerosol yields and the presence of unconsidered SOA precursors.

As one type of anthropogenic VOC and potential SOA precursors, cyclic volatile methyl siloxanes (cVMS)
are widely used in industrial applications and personal care products (Genualdi et al., 2011; Krogseth et al.,





45	2013a). cVMS have been classified as high-volume chemicals with an annual production of millions of tons
46	globally (Rücker and Kümmerer, 2015; Ahrens et al., 2014). Studies of cVMS in the environment have
47	focused on investigating health and environmental impacts particularly due to their potential persistence,
48	bioaccumulation and toxicity (Guo et al., 2019; Liu et al., 2018; Farasani and Darbre, 2017; Xu et al., 2019;
49	Kim et al., 2018; Coggon et al., 2018). As a result, the European Council has proposed a restriction on the
50	octamethylcyclotetrasiloxane (D4) and decamethylcyclopentasiloxane (D5) content in wash-off personal
51	care products to a limit of 0.1 mass% by 2020. The legislative actions notwithstanding, knowledge of
52	environmental behavior of cVMS remains surprisingly scarce as compared to their applications and
53	economic significance (Rücker and Kümmerer, 2015).

54 It has been estimated that approximately 90% of cVMS are emitted into the atmosphere due to their high 55 saturation vapor pressures (Allen et al., 1997). Gas-phase cVMS have been observed in both indoor and 56 outdoor air. Tang et al. (2015) reported that cVMS accounted for about one third of total VOC mass 57 concentration in a classroom. Outdoor air concentrations of cVMS have also been measured at different sites worldwide (Li et al., 2020; Wang et al., 2018; Rauert et al., 2018), increasing from rural to urban sites and 58 59 consistent with increasing population density (Rücker and Kümmerer, 2015). For example, at a rural site in 60 Sweden, the concentration of hexamethylcyclotrisiloxane (D3), D4, D5 and dodecamethylcyclohexasiloxane (D6) were 0.94, 3.5, 13 and 1 ng/m³, respectively (Kierkegaard and Mclachlan, 2013), while they were 18, 61 62 55, 172 and 14 ng/m³ in urban areas of Toronto in Canada, respectively (Genualdi et al., 2011; Rauert et al., 63 2018). cVMS have also been detected in the remote Arctic atmosphere, confirming their long-range transport 64 (Genualdi et al., 2011; Krogseth et al., 2013b). Atmospheric half-lives of cVMS are on the order of 30, 15, 65 10 and 1.6 days for D3-D6, respectively, which allow cVMS to exhibit a hemispherical distribution in the 66 atmosphere (Whelan et al., 2004; Allen et al., 1997; Yucuis et al., 2013; Xiao et al., 2015; Macleod et al.,





67 2013). These lifetimes are driven mostly by reactions with the OH radicals (Xiao et al., 2015; Wang et al., 68 2013), which generate silanols and dimeric products that can be partitioned to condensed phases (Coggon et al., 2018; Sommerlade, 1993; Wu and Johnston, 2016). The loss of cVMS in the atmosphere is slight through 69 70 O3 and NO3 due to their small reaction rates, and by Cl atoms on account of its low concentration (Atkinson, 71 1991; Alton and Browne, 2020). 72 It has been demonstrated that elemental Si is a frequent constituent of nanoparticles in rural and urban 73 areas (Phares et al., 2003; Rhoads, 2003; Bein, 2005; Bzdek et al., 2014) and in remote regions (Li and 74 Winchester, 1990; Li and Winchester, 1993). These Si-containing nanoparticles have previously been 75 attributed to ore smelting processes, but recent studies have shown that Si-containing species are one of the 76 main components in cVMS SOA, suggesting that the oxidation of cVMS may be an important source of Si 77 in atmospheric aerosols (Wu and Johnston, 2016, 2017). In a modeling study, the oxidation products of 78 cVMS (D4, D5 and D6) were considered to quantify the maximum potential for aerosol formation through 79 reactions with the OH radicals (Janechek et al., 2017). Chandramouli and Kamens (2001) demonstrated the 80 gas-particle partitioning of silanols from D5 oxidation by the OH radicals. Wu and Johnston (2016, 2017) 81 analyzed the chemical composition of secondary aerosols from OH oxidation of D4 and D5, showing a large 82 number of monomeric and dimeric products. Janechek et al. (2017, 2019) reported physical properties of 83 SOA generated by OH oxidation of D5, including hygroscopicity, cloud seeding potential and volatility. 84 Charan et al. (2021) measured SOA yields of D5 using chambers and flow tube reactors, indicating necessary 85 conditions when extrapolating SOA yields to the ambient atmosphere. These studies mainly focused on D5 86 and occasionally D4 but rarely others. To better understand the SOA-forming potentials of typical cVMS in 87 the atmosphere, accurate yields and molecular compositions of SOA from the oxidation of cVMS under 88 various atmospheric conditions are needed.





89	In this work, the formation of SOA from the oxidation of four cVMS (D3-D6) by OH radical was
90	investigated in an oxidation flow reactor (OFR). Under various combinations of NO _x and ammonium sulfate
91	seed concentrations, the yields and compositions of SOA formed from the oxidation were measured using a
92	suite of instruments including a scanning mobility particle sizer (SMPS), a proton transfer reaction time of
93	flight mass spectrometer (PTR-ToF-MS) and an aerosol mass spectrometer (AMS). Based on these SOA
94	yields, the contribution of cVMS to SOA in the global atmosphere was estimated using reported cVMS
95	concentrations. The results obtained here can largely improve our understanding of the contribution and
96	composition of SOA from cVMS.
97	2 Experiments and methods
98	2.1 Photo-oxidation experiments
99	The reactions of cVMS with OH radicals were controlled at a constant temperature (21±1°C) and relative
100	humidity (35%±2%) in a custom-made oxidation flow reactor (the Environment and Climate Change Canada
101	oxidation flow reactor, ECCC-OFR), which is shown in Fig. S1 of the Supplement and has been described
102	in detail previously (Li et al., 2019a). Briefly, the ECCC-OFR is a fused quartz cylinder (length: 50.8 cm,
103	inner diameter: 20.3 cm) equipped with a conical inlet and 7 outlets. Wall losses of particles and gases in the
104	ECCC-OFR have been shown to be lower than in other OFRs (Huang et al., 2017; Lambe et al., 2011;
105	Simonen et al., 2017; Li et al., 2019a). The length and full angle of cone inlet are 35.6 cm and 30°,
106	respectively, designed to minimize the formation of jetting and recirculation in the OFR. The outlet at the
107	reactor center is a stainless-steel sampling port (inner diameter: 0.18 in) extending 12.7 cm long into the
108	ECCC-OFR. This sampling inlet reduces the impact of potential turbulent eddies caused by the back end of
109	the reactor. The remaining 6 outlets around the perimeter are designed to allow side flows to pass through
110	the OFR as a sheath flow, indirectly reducing wall losses of gases and particles inside the OFR upon sampling.



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- Ozone-free mercury UV lamps for generating OH radicals are housed in small quartz tubes around and in parallel to the quartz reaction cylinder, and a large flow of air through each of these smaller quartz tubes is
- 113 used to remove the heat produced by the lamps. The relative humidity was adjusted by controlling the ratio
- 114 of dry air to wet air into the reactor, and was measured using a humidity sensor (Vaisala) at one of the sheath
- 115 flow outlets (side flows) of the reactor. The volume of the entire ECCC-OFR is about 16 L and the total flow
- 116 rate is 8 L min⁻¹, leading to a residence time of 2 min in the OFR.

OH radicals were produced through the reaction of water vapor with O(¹D) formed from O₃ photolysis at 254 nm. The OH concentration in the ECCC-OFR was regulated by controlling the input voltage and the number of UV lamps. Methanol vapor, introduced into the ECCC-OFR through a bubbler containing methanol solution, was used to determine the OH exposure (i.e., photochemical age) by tracking its decay in the reactor from the reaction with the OH. The decay, or fractional loss, of gas-phase methanol, [MeOH]/[MeOH]₀ was measured with the PTR-ToF-MS, and was used to calculate the OH concentration via Equation 1,

 $[OH] = \frac{1}{k_{MeOH}} ln \frac{[MeOH]}{[MeOH]_0}$ (1)

where k_{MeOH} is the second-order rate constant of methanol reaction with OH at 298 K (9.4×10⁻¹³ cm³ molecule⁻¹ s⁻¹). It was noted that the OH exposure measurement was offline, because methanol can affect the OH reactivity with cVMS. Under low and high-NO_x conditions described below, the OH exposure varied in the range of 5.5×10^{10} - 1.8×10^{12} and 8.2×10^{10} - 1.1×10^{12} molecules cm⁻³ s, respectively. They correspond to 0.4-14.2 and 0.6-8.5 equivalent days (photochemical age), respectively, assuming that an average OH concentration in air is 1.5×10^6 molecules cm⁻³ (Mao et al., 2009).

Pure D3-D6 cVMS compounds (solid D3 and liquid D4, D5 and D6) were placed in a glass U-type tube
and maintained at the room temperature. Vapors from these compounds (Table S1 of the Supplement) were





133	separately introduced into the ECCC-OFR by a small flow of zero air (1-18 mL min ⁻¹) passing over the
134	headspace of the U-tube containing the pure compounds. The concentrations of D3-D6 in the ECCC-OFR
135	ranged from 20 to 40 ppb, depending on their volatilities. To study the influence of existing particles on the
136	SOA formation, ammonium sulfate (AS) seed particles were produced using an atomizer, dried by a diffusion
137	dryer and neutralized by a neutralizer and injected into the reactor without size selection. The mass
138	concentration of AS seed particles was approximately 30 μ g m ⁻³ for all experiments.
139	N ₂ O was used as a source of NO to achieve high-NO _x conditions (Lambe et al., 2017). NO _x conditions
140	were defined by the fate of peroxy radicals (RO ₂), which was described by the reaction rate ratio ($R_{\rm NO}$) of
141	$RO_2 + NO$ and $RO_2 + HO_2$ (Peng et al., 2017). The R_{NO} ratio increases with increasing OH exposures at a
142	constant concentration of N_2O (Li et al., 2019b). To achieve a constant branching ratio during the high- NO_x
143	experiments, the initial N ₂ O concentration in the OFR was varied (1.6%-8.0%) to maintain an $R_{\rm NO}$ value of
144	20 (Li et al., 2019b), as calculated using a model (OFR Exposures Estimator v3.1) (Peng et al., 2017). A
145	ratio of $R_{NO}=20$ indicates that 95% of RO ₂ reacts with NO, ensuring the dominance of RO ₂ + NO, which
146	represents conditions that are relevant for urban atmosphere (Peng et al., 2019). Under low-NO _x conditions,
147	N_2O was not introduced into the OFR, where the RO_2 radicals dominantly interacted with HO_2 radicals,
148	representing atmospheric scenarios with few NO _x sources.

149 2.2 Characterization and analysis

The concentrations of cVMS in the OFR were measured online with a proton transfer reaction time of flight mass spectrometer (PTR-ToF-MS, Ionicon Analytik GmbH) (Liggio et al., 2016). The number and mass size distribution of aerosols was monitored using a scanning mobility particle sizer (SMPS, TSI). The mass spectra and elemental composition of aerosols was determined with a high-resolution time-of-flight aerosol mass spectrometer (HR-ToF-AMS, Aerodyne) and analyzed with the AMS analysis software Squirrel



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- 155 (version 1.62G) and Pika (version 1.22G).
- 156 SOA mass yields (*Y*) were calculated via Equation 2,
 - $Y = \frac{\Delta C_{\rm SOA}}{\Delta C_{\rm eVMS}} \tag{2}$

where ΔC_{SOA} and ΔC_{cVMS} are the mass concentrations of SOA formed and cVMS lost, respectively. The mass

159 concentration of SOA was determined by multiplying the effective aerosol density by the integrated SOA

160 volume concentration from the SMPS, subtracting the AS seed volume for experiments with AS seeds. The

161 effective aerosol density (ρ) was calculated for unseeded experiments through the following Equation 3

162 (Lambe et al., 2015),

163
$$\rho = \frac{D_{va}}{D_m}$$
(3)

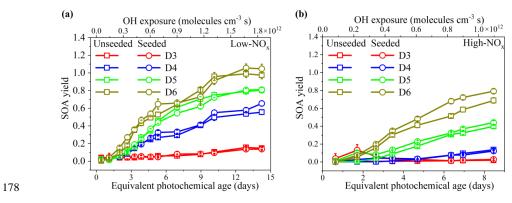
where D_{va} is the vacuum aerodynamic diameter obtained from the HR-ToF-AMS, and D_m is the electric mobility diameter measured by the SMPS. The ρ varied in the range of 1.6-1.8 depending on the cVMS. The same ρ value was also used in the seeded experiments.

- 167 **3 Results and discussion**
- 168 **3.1 SOA yields**

169 Figure 1 shows the SOA yields from the photooxidation of the D3-D6 cVMS under low and high-NOx 170 conditions as a function of photochemical age (PA), i.e., time-integrated OH exposure, with and without AS 171 seed particles. SOA yields have been widely used to estimate the potential of precursors to produce aerosol 172 mass (Mcfiggans et al., 2019; Li et al., 2019a; Bruns et al., 2015; Lambe et al., 2015). As shown in Fig. 1, 173 the cVMS SOA yields exhibited an overall increasing trend with PA, expressed in equivalent photochemical 174 days, which agreed with the trend of D5 SOA yields reported by Janechek et al. (2019). Under low-NOx 175 conditions (Fig. 1a), SOA yields exhibited a slow growth, reaching a plateau after 10 equivalent days. This may be due to increased gas-phase fragmentation of cVMS to generate some higher volatility products, 176







177 leading to a small increasing amplitude of partition ratio of species into SOA at longer photochemical ages.

Figure 1. SOA yields from unseeded and seeded (30 μg m⁻³) photooxidation of cVMS by OH radicals. (a)
low-NO_x experiments; (b) high-NO_x experiments.

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182 For the unseeded and low-NO_x experiments in Fig. 1a, SOA yields of four cVMS exhibited significant differences in values over the same number of equivalent days. The SOA yields successively increased from 183 184 D3 to D6, consistent with the volatilities and molecular masses of the cVMS as well as their reaction rate 185 constants with the OH radical (Alton and Browne, 2020; Kim and Xu, 2017; Safron et al., 2015). The 186 maximum SOA yields of D3-D6 were (0.16±0.02), (0.56±0.03), (0.80±0.03) and (0.99±0.04), respectively, 187 occurring after a PA of 12 equivalent days. It has been reported that D5 SOA yields varied in the range of 0.08-0.50 (Janechek et al., 2019; Wu and Johnston, 2017). Under a similar OH exposure $(1.6-1.7\times10^{12})$ 188 189 molecules cm^{-3} s), the D5 SOA yield (0.79±0.03) obtained here is considerably higher than that (0.22) 190 measured by Janechek et al. (2019), which may be attributed to differences in experimental conditions such 191 as differences in wall losses, SOA measurement methods, RHs, and D5 concentrations (Table S2). Although 192 the amount of cVMS lost was variable, cVMS SOA yields positively depended on SOA mass concentrations 193 (Fig. S2), and this trend was observed in previous D5 SOA experiments with OH oxidation (Wu and Johnston, 194 2017).





195	As shown in Fig. 1b, the order of SOA yields from the four cVMS under high-NO _x conditions was the
196	same as that under low-NO $_x$ conditions. However, the SOA yields under high-NO $_x$ conditions were generally
197	smaller than the corresponding yields at similar OH exposures under low-NO $_{\rm x}$ conditions, with a decrease
198	of 0.05-0.30 depending on the cVMS. Such a reduction suggests that NO_x can restrict the formation of cVMS
199	SOA. NO _x has been shown to reduce SOA yields for some anthropogenic alkanes (Li et al., 2019b), aromatics
200	(Ng et al., 2007a; Chan et al., 2009; Zhou et al., 2019), monoterpenes (Zhao et al., 2018) and other terpenes
201	(Ng et al., 2007b), attributable to the formation of higher volatility products (e.g., organic nitrates) generated
202	by $RO_2 + NO$ compared to $RO_2 + HO_2$ (Presto et al., 2005; Li et al., 2019b), which is also likely the case
203	here. The higher volatility products favor partitioning in the gas phase, thus reducing the potential for
204	forming SOA (Zhou et al., 2019). Moreover, high NO _x levels can suppress the formation of products for
205	nucleation, thereby reducing aerosol surface as a condensational sink and increasing the wall loss of
206	condensable species in an OFR under high-NO _x conditions (Zhao et al., 2018; Sarrafzadeh et al., 2016; Wildt
207	et al., 2014). Figure S3 indicates that the difference between SOA yields with and without NO_x decreased
208	with increasing silicon atoms within individual cVMS, indicating a less restricting effect of NO_x on the SOA
209	formation for larger cVMS. This means that high NO_x levels play a lessor role in the SOA yields of lower
210	volatility precursors.
211	SOA yields in the AS-seeded experiments under low and high-NO _x conditions are also shown in Figs. 1

and S3, indicating minimal impacts of the AS seed particles on SOA yields. A yield enhancement ratio $(R_E=Y_{secded}/Y_{unseeded}, Fig. S4)$ was used to show the seed impacts more clearly. Under low-NO_x conditions, the R_E values for all cVMS were close to 1.0 (Fig. S4a), suggesting negligible impact of AS seed particles on SOA yields; however, under high-NO_x conditions, R_E was much larger (17.81, 13.18 and 15.51 for D3-D5, respectively) at short PA but gradually decreased to 1.0 with increasing PA for D3-D5, while it was





217	always close to 1.0 for D6 regardless of PA (Fig. S4b). $R_{\rm E}$ values greater than 1.0 suggest that AS seed
218	particles played an enhancement role in the cVMS SOA formation, as similarly reported in SOA formation
219	from hydrocarbons (Sarrafzadeh et al., 2016; Lamkaddam et al., 2017; Li et al., 2019b). Under low-NO _x
220	conditions, the general lack of impact on cVMS SOA yields by the AS seed particles suggests that
221	condensation was not the main process driving SOA formation in cVMS oxidation. For the few cases of high
222	NO_x level at low PA, where R_E was >1 for D3-D5, it is possible that their early generations of oxidation
223	products were more volatile than successive generations of products and hence more prone to condensation
224	enhanced by AS seeds. As PA increased, further reactions of these early generation oxidation products with
225	OH radicals resulted in further generation products that were likely less volatile, thereby weakening the
226	enhancing role of AS seeds at high OH exposure. Such effect was less pronounced for D6, likely because its
227	oxidation products at different PA had similar volatilities. Figure S4b shows that the effect of AS seed
228	particles on SOA yields negatively correlated with the number of silicon atoms in the cVMS. Lower volatility
229	precursors (D5 and D6) formed lower volatile products (Alton and Browne, 2020), resulting in SOA yields
230	less sensitive to the pre-existing seeds. In fact, the oxidation products of D5 have been shown to be nearly
231	non-volatile (Janechek et al., 2019; Wu and Johnston, 2017).

232 3.2 Aerosol compositions

233 **3.2.1** Compositions of SOA under low-NO_x conditions.

Figures 2 and S5 show the normalized HR-ToF-AMS mass spectra of cVMS SOA from unseeded experiments under low-NO_x conditions at OH exposures of 9.0×10^{11} molecules cm⁻³ s. The mass spectral signals can be identified as fragments with a formula of C_xH_yO_zSi_n. For D3 SOA, the most prominent peaks were at m/z 44 and 29, dominated by CO₂⁺ and CHO⁺, which were tracers for organic acids (Ng et al., 2010), alcohols and aldehydes (Lee et al., 2012), respectively. They may result from the oxidation of the methyl





- groups in D3 by OH radicals. For the mass spectra of D4-D6 SOA, the two highest peaks at m/z 14 and 15
- $240 \qquad \text{were } CH_2{}^+ \text{ and } CH_3{}^+ \text{, respectively. In addition, there were several dominant } C_xH_yO_zSi_n \text{ peaks, which were } Si_n P_2 Si_n$
- $241 \qquad fragments \ of \ silicon-containing \ products. \ For \ the \ C_xH_yO_zSi_n \ group \ in \ D4 \ SOA, \ there \ were \ four \ typical \ peaks$
- 242 at m/z 255, 257, 271 and 273, with formulae of $C_4H_{11}O_7Si_3^+$, $C_3H_9O_8Si_3^+$, $C_3H_7O_9Si_3^+$ and $C_3H_9O_9Si_3^+$, $C_3H_9O_9Si_3^+$, $C_3H_7O_9Si_3^+$ and $C_3H_9O_9Si_3^+$, $C_3H_9O_$
- 243 respectively. The CxHyOzSin fragment group containing Si of D5 SOA had three dominant peaks at m/z 327,
- 244 329 and 331, corresponding to $C_{12}H_{11}O_2Si_5^+$, $C_9H_9O_8Si_3^+$ and $C_5H_{15}O_9Si_4^+$, respectively. For the $C_xH_yO_zSi_n$
- group containing Si in D6 SOA, there were five main peaks at m/z 73 (C₃H₉Si), 387 (C₈H₂₃O₈Si₅⁺), 389
- 246 $(C_8H_9O_9Si_5^+)$, 401 $(C_9H_{21}O_{10}Si_4^+)$ and 403 $(C_7H_{15}O_{12}Si_4^+)$.

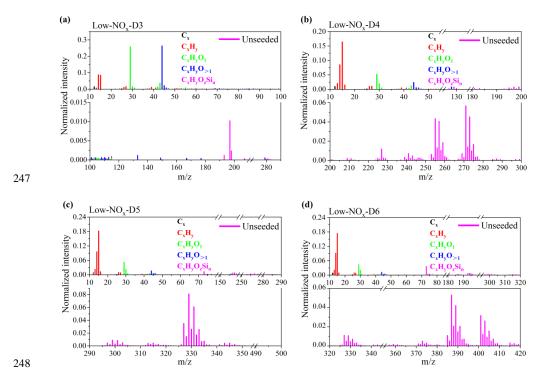


Figure 2. HR-ToF-AMS mass spectra of cVMS SOA at OH exposure of 9.0×10^{11} molecules cm⁻³ s under low-NO_x conditions in unseeded experiments. **a-d** represent the mass spectra of D3-D6 SOA, respectively.

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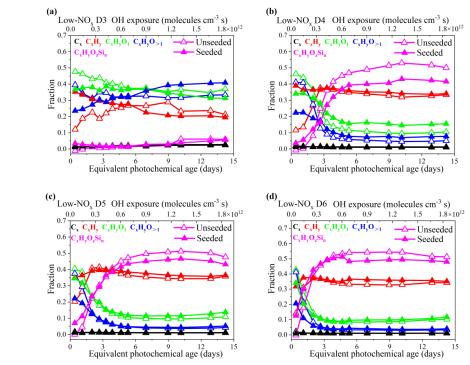


252	Figure 3 shows the evolution of different groups of ions in the HR-ToF-AMS spectra of the cVMS SOA
253	as a function of PA in equivalent days. For D3-D6 under unseeded conditions, $C_xH_yO_1$ and $C_xH_yO_{>1}$ ions
254	significantly decreased within 0-4 equivalent days of PA, but remained essentially unchanged when PA
255	increased to 7-15 equivalent days. The C_xH_y ion increased to its peak value at about 9 equivalent days of PA
256	for D3 and 2-3 equivalent days of PA for D4-D6, and then gradually decreased with further PA increases.
257	The C _x H _y O _z Si _n group of ions maintained an increasing trend until 9-10 days of PA, thereafter it decreased
258	slightly for D4-D6 SOA. The weighted values of the atomic number ratios Si/C (n/x) and Si/O (n/z) for the
259	$C_xH_yO_zSi_n$ groups in D5 and D6 SOA at different PA are plotted in Fig. S6, which can be used to indicate
260	the changes in the Si element of SOA. The n/x ratio at initial SOA formation stage was close to that (0.50)
261	in D5 and D6 molecules, and then increased continuously with increasing PA. The n/z ratio kept increasing
262	from 0.53 to 1.15 for D5 SOA and from 0.72 to 1.32 for D6 SOA, but varying around 1.0 that was the Si/O
263	ratio in D5 and D6. While it is difficult to separate the effect of fragmentation due to the AMS ionization
264	process, the relative changes of group intensities and the evolution of n/x and n/z in $C_x H_y O_z Si_n$ over different
265	PA may be attributed to the initial substitution of methyl groups on the -Si-O- ring of the cVMS by OH or
266	CH2OH when oxidized by the OH radicals (Wu and Johnston, 2016; Alton and Browne, 2020). Si-containing
267	products such as silanols may partition into SOA and result in an appearance of $C_xH_yO_zSi_n$ ions in the AMS
268	mass spectra. It is possible that in this process, the Si-O bonds may continue to be cleaved from OH radical
269	attack, followed by further deposition of less volatile and nonvolatile products containing $C_xH_yO_zSi_n$ on the
270	SOA.

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272 Equivalent photochemical age (days) Equivalent photochemical

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As shown in Fig. 3, the presence of seeds led to some changes in the evolution trends of ion groups in the AMS spectra. For instance, the initial fraction of C_xH_y in seeded experiments was larger than that in unseeded experiments, whereas $C_xH_yO_1$ and $C_xH_yO_{>1}$ exhibited opposite changes. The presence of seeds led to larger initial and smaller steady-state $C_xH_yO_zSi_n$ fractions than those in unseeded experiments. Regardless of the presence of seeds, C_xH_y , $C_xH_yO_1$ and $C_xH_yO_{>1}$ mainly contributed to the composition of all cVMS SOA at initial OH radicals oxidation, but D4-D6 SOA primarily consisted of C_xH_y and $C_xH_yO_zSi_n$ after 6 equivalent days.





284 **3.2.2** Compositions of SOA under high-NO_x conditions.

285	Figure S7 shows the HR-ToF-AMS mass spectra of cVMS SOA under high-NO $_{\rm x}$ conditions at OH
286	exposures of 9.0×10^{11} molecules cm ⁻³ s (-6.9 d). Compared to that under low-NO _x conditions (Figs. 2 and
287	S5), there was one additional N-containing group $(N_m O_z)$ in the SOA mass spectra under high-NO $\!_x$
288	conditions, which accounted for 16%-31%. For the mass spectra of D3-D6 SOA originating from unseeded
289	experiments under high-NO _x conditions in Fig. S7, the dominating peaks of the N_mO_z family were m/z 30
290	(NO ⁺) and m/z 46 (NO ₂ ⁺). The common main peaks were located at m/z 30 (NO ⁺) for cVMS SOA, m/z 44
291	(CO_2^+) for D3-D4 SOA, and m/z 46 (NO_2^+) for D4-D6 SOA. In addition, there were other primary peaks at
292	m/z 29 (CHO ⁺) for D4 SOA, while m/z 15 (CH ₃ ⁺) and m/z 28 (CO ⁺) for D5-D6 SOA. The m/z 28 (CO ⁺),
293	similar with m/z 44 (CO_2^+), is considered as a tracer for organic acids (Ng et al., 2010). In the mass spectra
294	for D3-D6 SOA under high-NOx conditions, the presence of NO ⁺ (m/z 30) and NO ₂ ⁺ (m/z 46) illustrated the
295	formation of nitrates in SOA (Ng et al., 2007b).
295 296	formation of nitrates in SOA (Ng et al., 2007b). For the $C_xH_yO_zSi_n$ group in the D4 SOA mass spectrum under high-NO _x conditions, the dominating peaks
296	For the C _x H _y O _z Si _n group in the D4 SOA mass spectrum under high-NO _x conditions, the dominating peaks
296 297	For the $C_xH_yO_zSi_n$ group in the D4 SOA mass spectrum under high-NO _x conditions, the dominating peaks and their formulas were same as those under low-NO _x conditions. For the $C_xH_yO_zSi_n$ group in D5 SOA, in
296 297 298	For the $C_xH_yO_zSi_n$ group in the D4 SOA mass spectrum under high-NO _x conditions, the dominating peaks and their formulas were same as those under low-NO _x conditions. For the $C_xH_yO_zSi_n$ group in D5 SOA, in addition to two typical peaks at m/z 327 and 329 in the low-NO _x experiments, there was another prominent
296 297 298 299	For the $C_xH_yO_zSi_n$ group in the D4 SOA mass spectrum under high-NO _x conditions, the dominating peaks and their formulas were same as those under low-NO _x conditions. For the $C_xH_yO_zSi_n$ group in D5 SOA, in addition to two typical peaks at m/z 327 and 329 in the low-NO _x experiments, there was another prominent peak at m/z 328, with a formula $C_8H_{12}O_5Si_5$. The $C_xH_yO_zSi_n$ group in D6 SOA had three typical peaks at m/z
296 297 298 299 300	For the $C_xH_yO_zSi_n$ group in the D4 SOA mass spectrum under high-NO _x conditions, the dominating peaks and their formulas were same as those under low-NO _x conditions. For the $C_xH_yO_zSi_n$ group in D5 SOA, in addition to two typical peaks at m/z 327 and 329 in the low-NO _x experiments, there was another prominent peak at m/z 328, with a formula $C_8H_{12}O_5Si_5$. The $C_xH_yO_zSi_n$ group in D6 SOA had three typical peaks at m/z 73 (C_3H_9Si), m/z 387 ($C_8H_{23}O_8Si_5^+$) and m/z 401 ($C_9H_{21}O_{10}Si_4^+$). For the $C_xH_yO_zSi_n$ groups in cVMS SOA,
296 297 298 299 300 301	For the $C_xH_yO_zSi_n$ group in the D4 SOA mass spectrum under high-NO _x conditions, the dominating peaks and their formulas were same as those under low-NO _x conditions. For the $C_xH_yO_zSi_n$ group in D5 SOA, in addition to two typical peaks at m/z 327 and 329 in the low-NO _x experiments, there was another prominent peak at m/z 328, with a formula $C_8H_{12}O_5Si_5$. The $C_xH_yO_zSi_n$ group in D6 SOA had three typical peaks at m/z 73 (C_3H_9Si), m/z 387 ($C_8H_{23}O_8Si_5^+$) and m/z 401 ($C_9H_{21}O_{10}Si_4^+$). For the $C_xH_yO_zSi_n$ groups in cVMS SOA, there was little difference in the x, y, z and n value assignment of $C_xH_yO_zSi_n$ peaks in SOA generated under

305 At equivalent days larger than 6, D3 SOA primarily consisted of C_xH_yO_{>1}, N_mO_z and C_xH_yO₁ groups, while





306	D4-D6 SOA was mainly composed of $C_xH_yO_zSi_n$, N_mO_z , $C_xH_yO_1$, C_xH_y and $C_xH_yO_{>1}$ groups. Figure S8 also
307	shows influences of seeds on the evolution of family groups under high-NO $_{\rm x}$ conditions. It was observed
308	that all groups in D3-D6 SOA displayed similar change trends regardless of the existence of seeds. As shown
309	in Fig. S9, the trend of the weighted values of the atomic ratio n/z in the $C_xH_yO_zSi_n$ groups at different
310	photochemical ages under high-NO _x conditions was similar to that in low-NO _x experiments. However, the
311	n/x ratios remained almost unchanged, and were close to the initial value (0.5) in cVMS. This may be
312	attributed to possible suppression of cleavage of methyl groups from the -Si-O- ring of the cVMS under
313	high-NO _x conditions.
314	4 Conclusions and implications
315	The yields and compositions of SOA generated from the photooxidation of four cVMS (D3-D6) with OH
316	radicals were investigated using an oxidation flow reactor. cVMS SOA yields exhibited an overall increasing
317	trend with PA, and their values gradually increased with cVMS from D3 to D6. SOA formations depended
318	on NO _x , as shown by smaller SOA yields under high-NO _x conditions. Ammonium sulfate seeds significantly
319	enhanced SOA yields of D3-D5 at short PA under high-NO _x conditions. The SOA mass spectra showed that
320	Si-containing species were one of main chemical compositions at PA of >6 days.
321	To evaluate the potential contributions of cVMS to SOA formation in the atmosphere, global SOA
322	concentrations produced from cVMS were estimated according to the cVMS SOA yields measured in this
323	work and using the cVMS concentrations reported from multiple studies, which were listed in Table S3.
324	Here, under the seeded conditions, the high-NO _x SOA yields at 8.5 equivalent days (D3: 0.028 ; D4: 0.122 ;
325	D5: 0.441; D6: 0.792) are employed in the calculation of cVMS SOA concentrations at urban sites, while
326	the low-NO _x SOA yields under the unseeded conditions at 14.2 equivalent days (D3: 0.148 ; D4: 0.556 ; D5:
327	0.805; D6: 0.975) are used to estimate cVMS SOA at background and polar sites. Figure 4 shows the global





- 328 concentration distribution of SOA from four cVMS (D3-D6) at 36 sites worldwide estimated by the Equation
- 329 4,

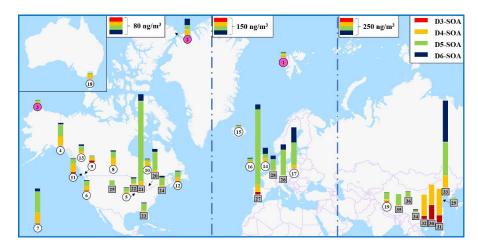
330

$$C_{\rm cVMS-SOA} = C_{\rm cVMS} \times \frac{\Delta C_{\rm cVMS}}{C_{\rm in-cVMS}} \times Y \tag{4}$$

331 where C_{cVMS} and C_{cVMS-SOA} are the mass concentration of cVMS reported from literatures and cVMS SOA 332 estimated in global sites, respectively; $C_{\text{in-cVMS}}$ and ΔC_{cVMS} are the mass concentration of initial and lost 333 cVMS at the selected equivalent days during the experiments of this work, respectively; Y is the cVMS SOA 334 mass yields mentioned above. Table S3 summarizes the details regarding sites and concentrations of cVMS 335 SOA. The derived concentrations of cVMS SOA varies significantly among urban, background and polar 336 sites. The total cVMS SOA concentrations in urban areas are the highest, up to 1249 ng/m³. They are 14.5-337 347 and 10.5-105.3 ng/m³ for background and Arctic sites, respectively. cVMS SOA concentrations in urban 338 regions of Asia (sites 29-36) and Europe (sites 26-28) are generally larger than that of North America (sites 339 20-25). In China, the total cVMS SOA concentrations in urban sites range from 14.7 to 1249 ng/m³. The 340 main precursors of cVMS SOA are different among Chinese cities. For three cities along the southeast coast 341 of China (Guangzhou, Macau and Foshan), the dominant precursors of cVMS SOA are D3 and D4, which 342 are related to industrial emissions of these two siloxanes in this region (Wang et al., 2001). For Dalian in 343 China, mainly D5 and D6 contribute to cVMS SOA, which have the highest concentrations among all sites. 344 This can be attributed to the industrial production of D5 and D6 and the use of personal care products in 345 Dalian (Li et al., 2020). In the other Chinese urban areas with reported cVMS concentrations (Lhasa, Golmud, Kunming and Yantai), the total cVMS SOA concentrations are considerably smaller than those in the urban 346 347 areas above, with D5 acting as the main precursor, which may be ascribed to the relatively low population 348 densities in these cities (Wang et al., 2018).







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Figure 4. Global concentrations of cVMS SOA (ng/m³) on the basis of the cVMS concentrations reported from multiple studies and the cVMS SOA yields measured in this work. The numbers of polar, background and urban sites are enclosed in pink, white circles and gray boxes, respectively. The details about cVMS and SOA concentrations at different sites were summarized in Table S3 of Supplement.

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At urban sites in Europe and North America, cVMS SOA concentrations are reported in the range of 131-
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        773 ng/m3 and 21.8-416 ng/m3, respectively. Among these cVMS, D5 is the main contributor to cVMS SOA
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        at these locations, averaging 80.4% of total cVMS SOA. This contribution is higher than that (73.9%) at
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        Chinese urban sites. For instance, D5 SOA is calculated to be 652 ng/m3 in Catalan, Spain, 369 ng/m3 in
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        Chicago, USA, 218 ng/m<sup>3</sup> in Zurich, Switzerland and 94 ng/m<sup>3</sup> in Paris, France, where there are high levels
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        of economic activities and high population densities. These results suggest that personal care products as a
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        main source of D5 may be the most important anthropogenic origins of Si-containing SOA in Europe and
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        North America.
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At background and Arctic sites, cVMS SOA are primarily derived from D4 and D5. The background sites
 are located in mountains, rural areas, forested areas, lakes and at high altitudes. The three highest cVMS





365	SOA concentrations at background sites are located at Kosetice in the Czech Republic (347 ng/m ³), Hilo,
366	Hawaii, USA (157 ng/m ³) and Tibetan Plateau in China (134 ng/m ³), where the contribution percentages of
367	SOA from both D4 and D5 are 61.9%, 90.3% and 94.9%, respectively. The cVMS SOA concentrations at
368	the Little Fox Lake site in Yukon, Canada is the highest (105.3 ng/m^3) among the four locations in the Arctic,
369	91% of which is accounted for by both D4 and D5 SOA. The dominance of D4 and D5 SOA in both
370	background and the Arctic regions highlights their persistence in atmosphere and the potential for long-range
371	atmospheric transport.
372	Furthermore, global concentration distribution of Si-containing SOA estimated for the four cVMS (D3-
373	D6) at 36 sites worldwide is also presented in Table S3, which clearly shows the global importance of Si in
374	SOA with the estimated percentages of cVMS SOA that contains the Si element. For example, up to 49.6%
375	and 31.2% of cVMS SOA contained Si elements in background and urban sites, respectively. These results
376	are similar to the summary observations that reported percentages of aerosols with a Si mole fraction >0.01
377	(%) at different sites (Bzdek et al., 2014). The above results demonstrated that Si is a frequent component of
378	SOA in background and urban areas.
379	The global annual production of D4, D5 and D6 is about 1, 0.1 and 0.01 Tg·yr ⁻¹ , respectively, and 90% of
380	these cVMS is eventually released into the atmosphere (Li et al., 2020; Genualdi et al., 2011; Wang et al.,
381	2013; Sakurai et al., 2019). Based on the results shown in Fig. 4, the annual production of cVMS (D4-D6)
382	SOA was estimated to be 0.16 Tg·yr ⁻¹ , which was about 5.5% of SOA (2.9 Tg·yr ⁻¹) produced from mobile
383	source emissions in the USA and 5-8 times of SOA generated by Athabasca oil sands (0.02-0.03 Tg·yr ⁻¹ , one
384	of the largest sources of anthropogenic secondary organic aerosols in North America) (Tkacik et al., 2014;
385	Liggio et al., 2016). Moreover, it was also 0.8% and 2.3% of isoprene-SOA (20 Tg·yr ⁻¹) and monoterpenes-
386	SOA (7 Tg·yr ⁻¹) (typical biogenic SOA), respectively, indicating the potential importance of cVMS SOA





- 387 (Jokinen et al., 2015). While these cVMS SOA sources may seem small, they can make substantially higher
- 388 contributions to ambient air SOAs in population centers where cVMS compounds are primarily used.
- 389

390 Author contributions

- 391 CH designed and conducted all experiments; CH and HY analyzed the data and prepared the paper with
- 392 contributions from KL, PL, JL, AL and SML. SML supervised the project.
- 393

394 Competing interests

395 The authors declare that they have no conflict of interest.

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